



Graphene-like MoS₂ prepared by a novel intercalation-detonation method

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ABSTRACT

Graphene-like MoS₂ has attracted significant interest because of its unique electronic, optical and catalytic properties with two-dimensional lamellar structure. A novel intercalation-detonation method was used to prepare monolayer and multilayer graphene-like MoS₂. MoS₂ was first completely intercalated by abundant oxygen-containing functional groups bonded to the sulfur atom layer in basal planes of the MoS₂ structure, increasing the layer spacing and decreasing the Van-der-Waals' force between the layers. Then, the intercalated MoS₂ was rapidly exfoliated by high energy of detonation. Characterization results indicate that the graphene-like MoS₂ was successfully prepared by the explosion method. This type of processing is simple, highly efficient and generates fewer impurities.

1. Introduction

Graphene-like molybdenum disulfide (MoS₂) is a new two-dimensional (2D) layered material, which has recently attracted considerable attention because of its unique structure, optical and electronic properties [1]. Unlike conductive graphene, bulk crystalline MoS₂ is a semiconductor with an indirect band gap of about 1.2 eV, which gradually increases with the reduction of the number of layers. Atomically layered MoS₂ is a semiconductor material with direct band gap, and the single-layer MoS₂ band gap is 1.9 eV [2].

Due to the adjustable band gap, graphene-like MoS₂ has a bright future for applications in photoelectronic devices. However, it is hard to obtain layered graphene-like MoS₂ by using conventional chemical or physical methods. Recently, micromechanical exfoliation [3], Li⁺ intercalation [4], liquid ultrasonic [5], hydrothermal method [6], and chemical vapor deposition [7] have been used to prepare graphene-like MoS₂. Still, some deficiencies hinder the development of this attractive material, such as poor repeatability, time consumption, low efficiency and product quality, etc. Thus, reproducible production of graphene-like nanosheets in bulk quantities is still a challenge.

Here, we report a novel intercalation-detonation method to prepare graphene-like MoS₂. It is the first time to use oxygen-containing groups as intercalation compound of layered structure MoS₂ and take advan-

tage of explosion technology to exfoliate intercalated MoS₂. As-prepared graphene-like MoS₂ is systematically characterized, and the exfoliation mechanism is proposed.

2. Materials and methods

2.1. Materials preparation

Raw materials, MoS₂ powder, picric acid (PC), NaNO₃ and KMnO₄ were pure AR grade, and 98% concentrated sulfuric acid was used to oxidize bulk MoS₂. Typical preparation procedure is as follows. 5 g of MoS₂ powder and 2.5 g NaNO₃ were dissolved in 200 ml of 98% concentrated sulfuric acid. The reaction flask was placed in an ice bath with violent stirring, and 15 g KMnO₄ was added slowly to avoid sudden increase in temperature. After 2 h reaction, the flask was heated to 35 °C and 90 °C held for 30 min in series. The reactive solution was diluted during stirring. The solution was filtered and thoroughly washed with deionized water until the pH of the filtrate became neutral. After filtration, the intercalation MoS₂ was obtained. The intercalation MoS₂ slurry was dried in a vacuum oven at 60 °C before use.

Exfoliation was performed by placing premixed intercalation MoS₂ (2 g) and picric acid (2 g) in a sealed stainless steel pressure vessel.

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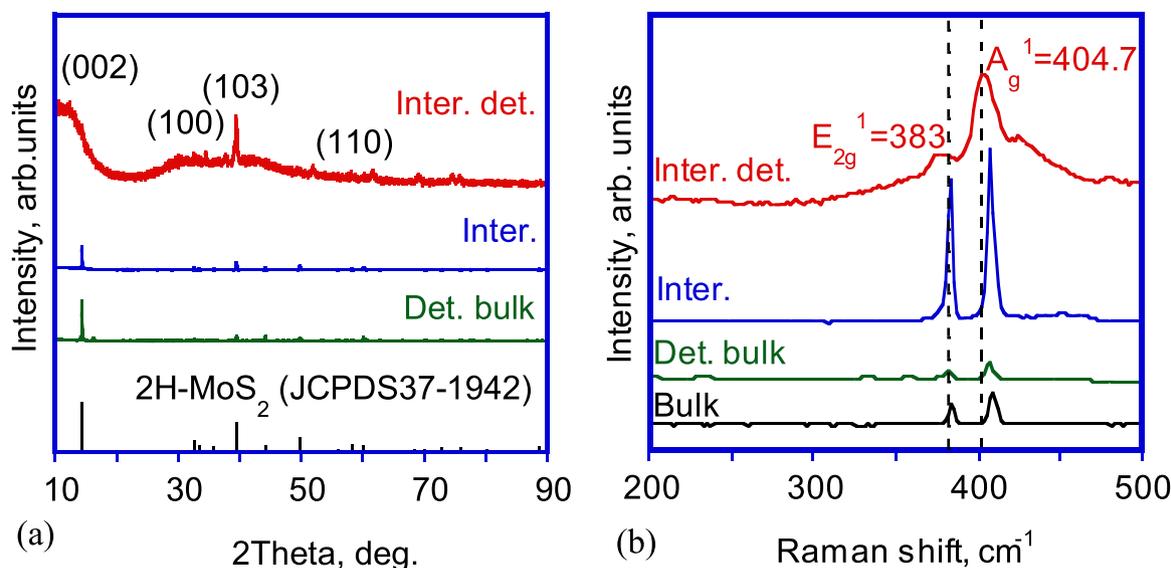


Fig. 1. (a) XRD patterns and (b) Raman spectra of detonated bulk MoS₂, intercalation MoS₂ and intercalation-detonation MoS₂ samples.

Detonation was induced by rapid heating at 50 °C/min to 400 °C. After detonation, the vessel was cooled in air, and generated gaseous products were released, while solid products were collected as the final sample of graphene-like MoS₂. The exfoliation sample of bulk MoS₂ was prepared using the same procedure.

2.2. Characterization

As-prepared samples were characterized by X-ray diffraction (XRD, Bruker, Germany), Raman spectroscopy (Jobin Yvon HR-800), atomic force microscopy (AFM, Bruker, Germany), high resolution transmission electron microscopy (HR-TEM, Fischione M3000) and X-ray photoelectron spectroscopy (XPS, PHI-5400, USA). The samples for AFM and HR-TEM examinations were dispersed in ethanol with ultrasonic treatment for 30 min before loading onto the carrier.

3. Results and discussion

3.1. XRD and Raman spectroscopy

XRD patterns were used to detect the phase change of MoS₂ samples, as shown in Fig. 1(a). In general, the exfoliation of MoS₂ results in the significantly reduction of the (002) reflection intensity, and even causes this peak to disappear. The spectra in Fig. 1(a) show that the (002) reflection was almost not present for the intercalation-detonation MoS₂, while other main peaks can be indexed to the 2H polytype of MoS₂ crystal structure (JCPDS 37-1492). Besides, the peaks can be indexed to the 2H polytype of MoS₂ crystal structure while the (002) peaks present strong intensity for detonated bulk and intercalation MoS₂. This indicates that the processing procedure didn't change the hexagonal crystal structure of MoS₂, and few- or monolayer MoS₂ was obtained after the intercalation-detonation process.

Raman spectra are shown in Fig. 1(b). MoS₂ nanosheets have peaks at 383 cm⁻¹ and 405 cm⁻¹ corresponding to the vibrational modes of E_{2g}¹ and A_{1g}¹, which is consistent with previous results [8]. From Fig. 1(b), it can be seen that Δk for the intercalation-detonation MoS₂ sample is 21.7 cm⁻¹, indicating that the few-layer MoS₂ nanosheets were obtained. However, Δk for the detonated bulk and intercalation MoS₂ samples are larger than 25 cm⁻¹, revealing the multilayer characteristics of MoS₂.

3.2. TEM and AFM morphology

Fig. 2. shows TEM and AFM images of the intercalation-detonation MoS₂ samples. A large area of the single layer structure can be seen at the edge of the sample in Fig. 2(a), exhibit multi-layer structure of the graphene-like MoS₂ nanosheet. In addition, high resolution TEM morphology in Fig. 2(b) and (c) exhibits high crystallinity of the layered MoS₂ with the 6.2 Å interplanar spacing. Selected-area electron diffraction pattern is shown in the inset of Fig. 2(b) and is well-indexed as a pure hexagonal MoS₂ phase.

AFM morphology in Fig. 2(d) shows the thickness image of the as-prepared intercalation-detonation MoS₂ samples. The 2 nm calculated average thickness indicates the presence of 3 layers, where the thickness of MoS₂ sheets is 0.65 nm per layer, also indicates that the layered structure of graphene-like MoS₂ was obtained.

3.3. XPS spectra

XPS measurements were carried out to characterize the chemical nature of the intercalation and intercalation-detonation MoS₂ samples. The XPS survey spectra show the co-existence of Mo, S, O and C elements, as seen in Fig. 3(a). High-resolution Mo 3d and S 2p spectra show peak locations corresponding to the Mo 3d_{3/2}, Mo 3d_{5/2}, S 2p_{1/2} and S 2p_{3/2} components of MoS₂, respectively (Fig. 3(b) and (c)) [9].

From Fig. 3(d), the high-resolution O 1s spectrum of intercalation MoS₂ shows that the peak at 533 eV is related to the S–OH bond [10], which indicates that the oxygen-containing functional groups were bonded to the surface or sulfur atom layer of MoS₂ during intercalation process. The O 1s spectrum of intercalation-detonation MoS₂ shows peaks at 531.4 and 533.3 eV, which are ascribed to the hydroxyl groups and S–OH, respectively [10]. Additionally, the peak intensity at 533.3 is much smaller than that of 531.4 eV, which proves that most of S–OH bonds were decomposed and converted to hydroxyl groups during detonation process.

3.4. Exfoliation mechanism

Based on the above analysis, the exfoliation mechanism of bulk MoS₂ is proposed in Fig. 4. First, MoS₂ was completely intercalated into intercalation MoS₂, resulting in abundant oxygen-containing

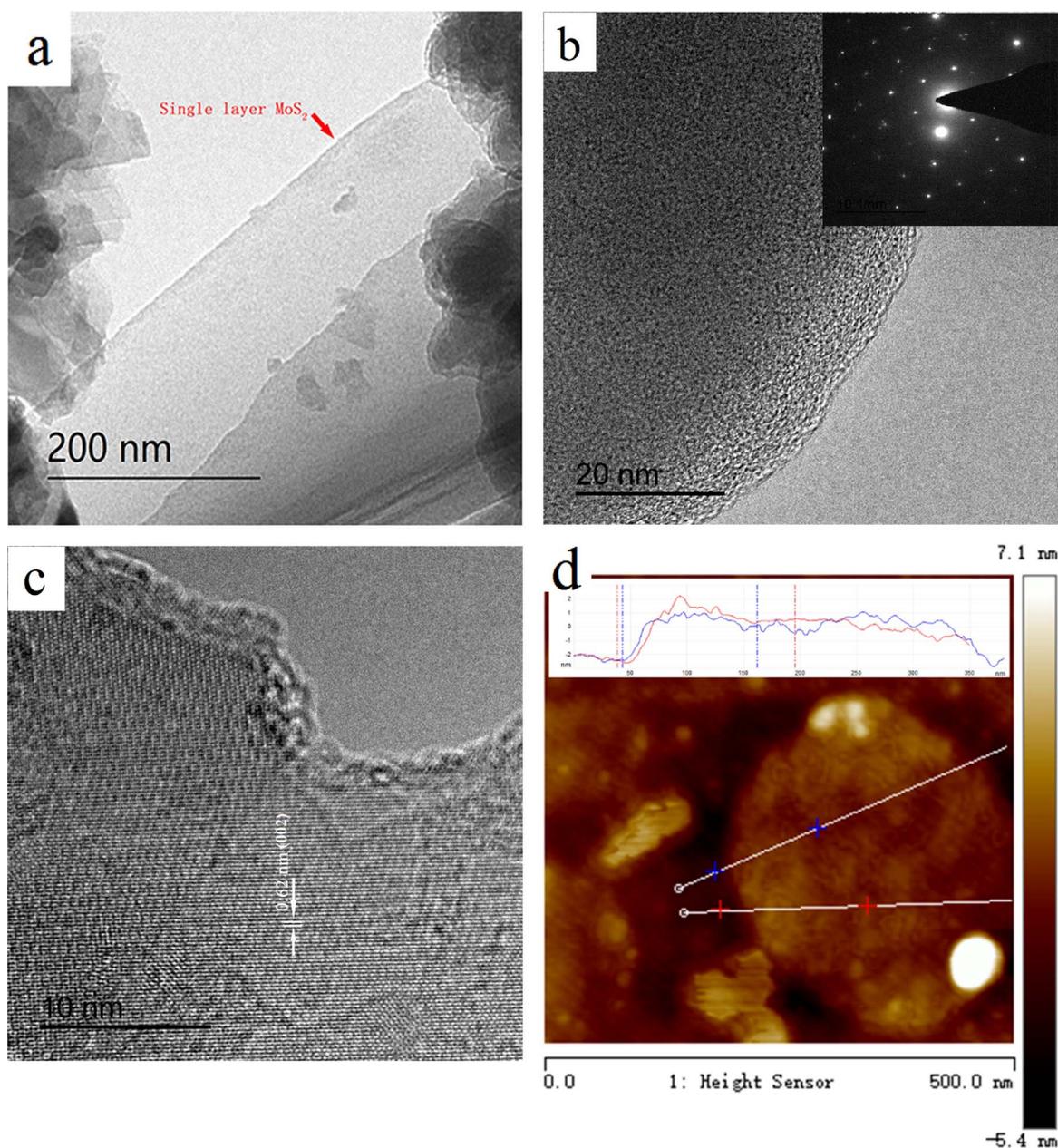


Fig. 2. (a–c) TEM and (d) AFM morphology of the intercalation-detonation MoS₂ sample.

functional groups bonded to the sulfur atom layer in basal planes of the MoS₂ structure. Then, the detonation was induced by rapid heating and the intercalation MoS₂ was rapidly heated to high temperature, inducing its oxygen-containing functional groups to be decomposed into CO₂ and H₂O. Expansion of the gases evolved into the interstices between the adjacent MoS₂ sheets resulted in the MoS₂ exfoliation.

4. Conclusions

In conclusion, crystalline graphene-like MoS₂ nanosheets were exfoliated from bulk MoS₂ through the novel intercalation-detonation procedure. Characterization by XRD, Raman and XPS spectroscopy, TEM and AFM indicates that the as-prepared samples have high crystallinity, layered graphene-like MoS₂ nanosheets structure with a single or few layers. The new method of detonation is a simple and

highly efficient way to exfoliate substantial materials, which exhibits good prospects for various applications. This preparation method of graphene-like MoS₂, might be applied to other 2D layered materials.

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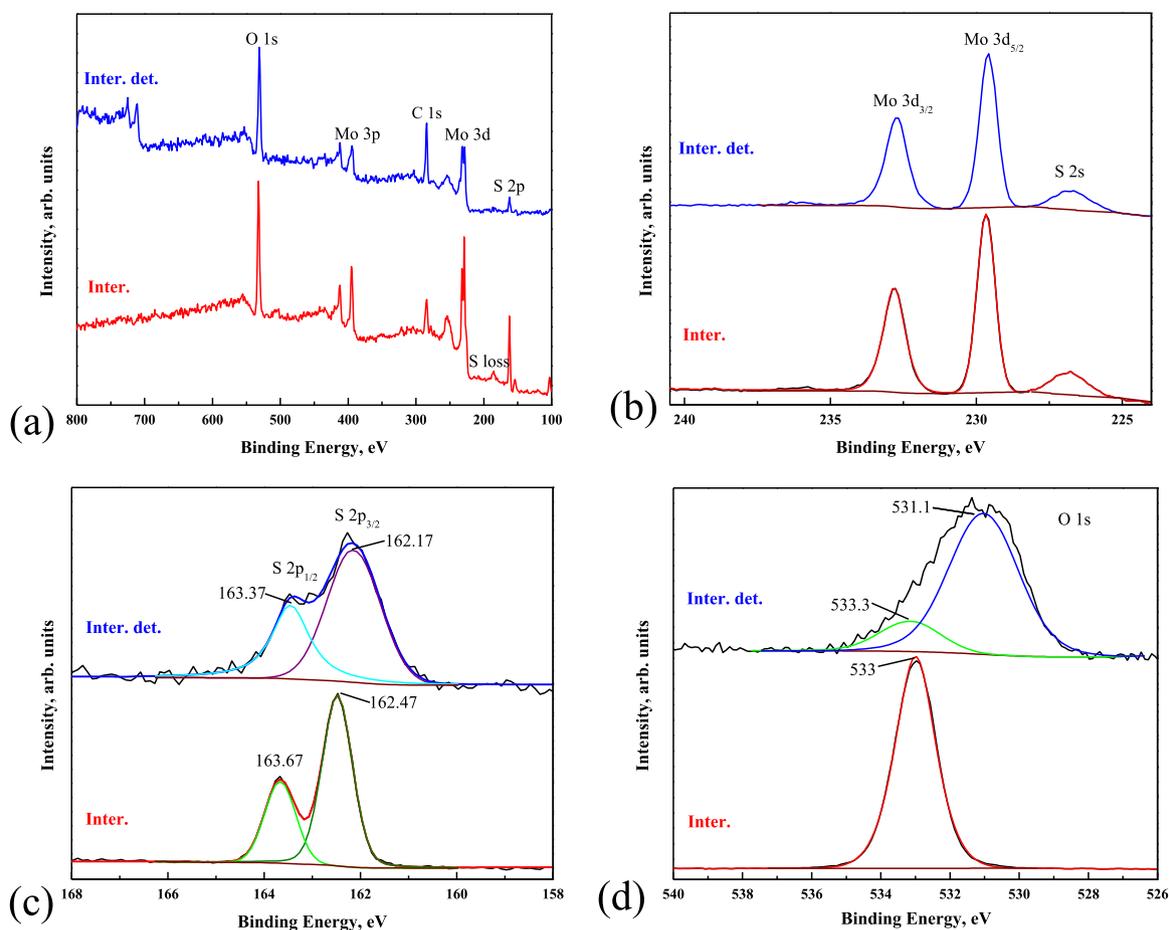


Fig. 3. (a) XPS survey spectrum of intercalation-detonation MoS₂ and high resolution scans of (b) Mo 3d, (c) S 2p and (d) O 1s.

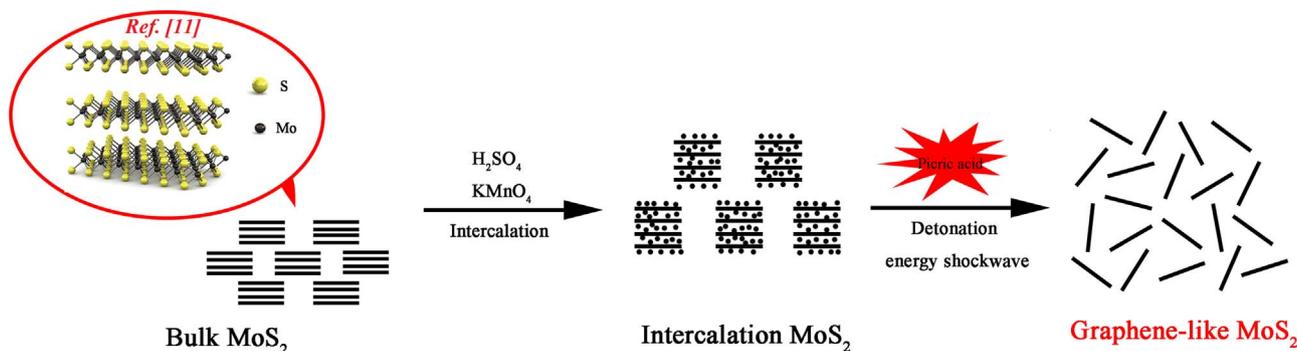


Fig. 4. Schematic illustration of the MoS₂ exfoliation mechanism [11].

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